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FIG. 1

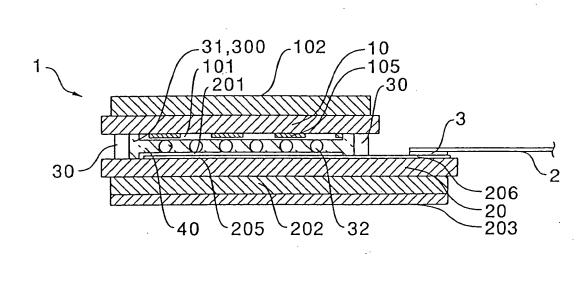
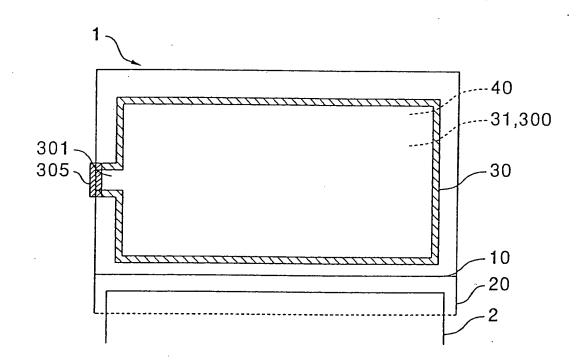


FIG. 2



[FIG. 3

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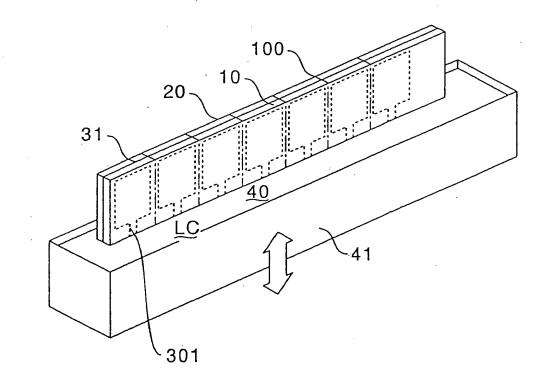


FIG. 4

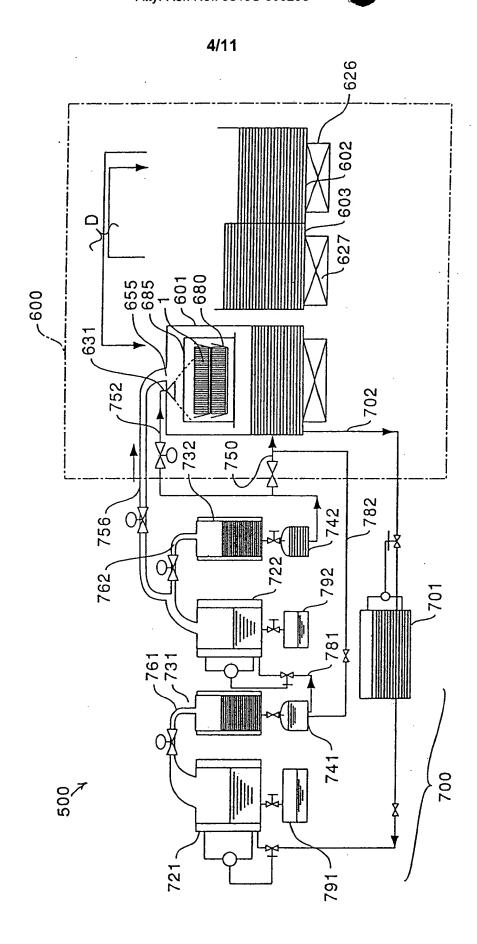
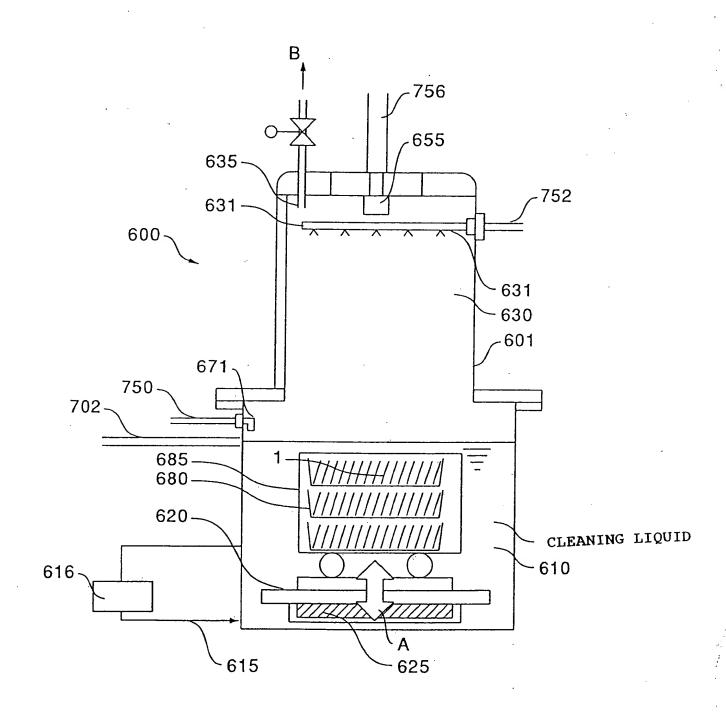


FIG. 5

5/11

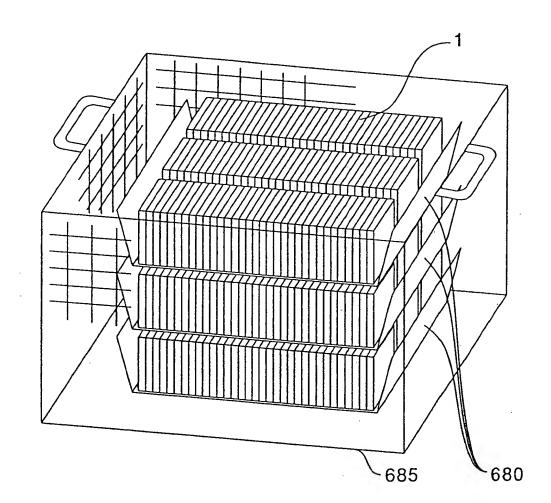


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FIG. 6

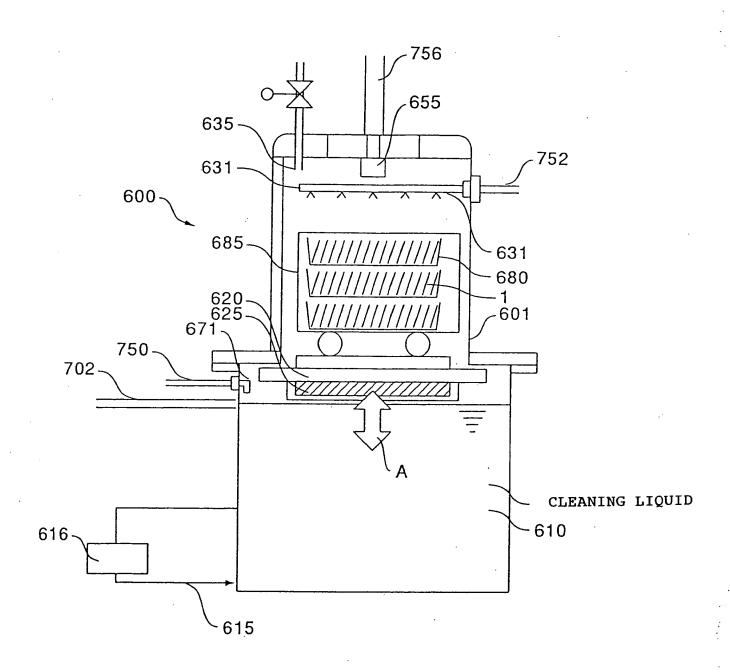
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FIG. 7]

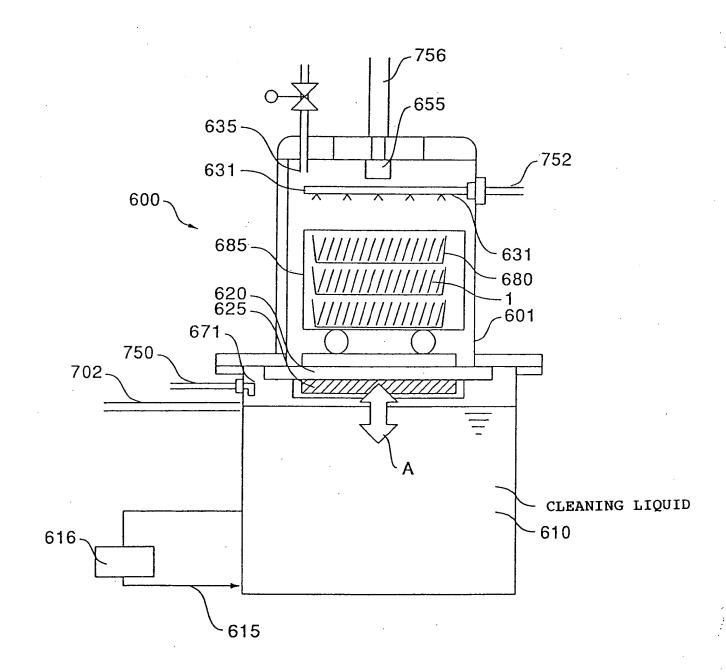
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DRAFTSMANI 134 030 Atty. Ref. No.: 9319S-000235

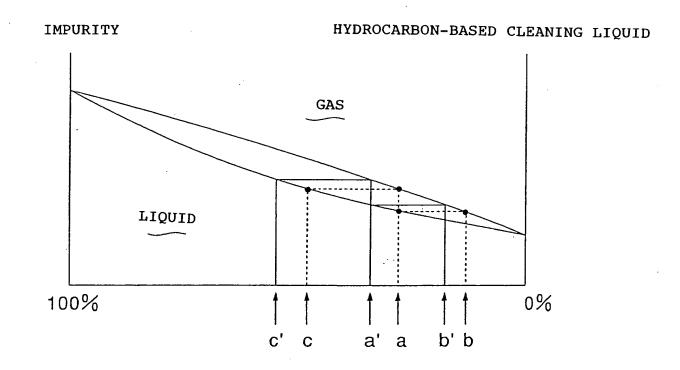
FIG. 8



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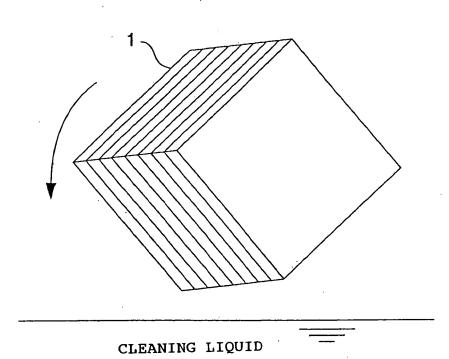
FIG.9



BY CLASS SUFFILE: CLEANING METHOD AND METHOD FOR MANUFACTURING LIQUID CRYSTAL DEVICE ventors: Yoichi ONO and Shinji HASHIKU

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FIG. 10,



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FIG. 11

